

*“Shuffling atomic layer deposition gas sequences to modulate bimetallic thin films and nanoparticle properties”*. Filez M, Feng J-Y, Minjauw MM, Solano E, Poonkottil N, Van Daele M, Ramachandran RK, Li C, Bals S, Poelman H, Detavernier C, Dendooven J, Filez M, Minjauw M, Solano E, Poonkottil N, Li C, Bals S, Dendooven J, *Chemistry of materials* (2022). <http://doi.org/10.1021/acs.chemmater.2c01304>